

## **Special Issue on Thin Film Materials and Its Applications**

## **Call for Papers**

Thin films are important because they offer the potential for low-cost processing with minimal material usage while fulfilling application requirements. Importantly, this can enable cost-effective applications for expensive raw source materials. Thin films also can enable applications where low weight and mechanical flexibility are crucial. The goal of this special issue is to provide a platform for scientists and academicians all over the world to promote, share, and discuss various new issues and developments in the area of **thin film materials and its applications**.

In this special issue, we intend to invite front-line researchers and authors to submit original research and review articles on exploring **thin film materials and its applications**. Potential topics include, but are not limited to:

- Film deposition methods
- Modes of film growth by vapor deposition
- Film microstructures
- Processing of microelectronic structures
- Film stress and substrate curvature
- Thin Film materials and devices
- Thin Film Processes

Authors should read over the journal's <u>For Authors</u> carefully before submission. Prospective authors should submit an electronic copy of their complete manuscript through the journal's <u>Paper Submission System</u>.

Please kindly specify the "**Special Issue**" under your manuscript title. The research field "**Special Issue -** *Thin Film Materials and Its Applications*" should be selected during your submission.

Special Issue Timetable:

Submission Deadline	November 18th, 2020
Publication Date	January 2021

## **Guest Editor:**

For further questions or inquiries, please contact Editorial Assistant at <u>ampc@scirp.org</u>.